640 (H) x 480 (V) Interline CCD Image Sensor

Description

The KAI–0340 image sensor is a 640 (H) \times 480 (V) resolution, 1/3" optical format, progressive scan interline CCD. This image sensor is offered in 2 versions: the KAI−0340−Dual supports 210 full resolution frame-per-second readout while the KAI−0340−Single supports 110 frame-per-second readout. Frame rates as high as 2,000 Hz (KAI−0340−Single) and 3,400 Hz (KAI−0340−Dual) can be achieved by combining the Fast Horizontal Line Dump with custom clocking modes. Designed for demanding imaging applications, the KAI−0340 provides electronic shuttering, peak QE (quantum efficiency) of 55%, extremely low noise and low dark current. These features give this sensor exceptional sensitivity and make it ideal for machine vision, scientific, surveillance, and other computer input applications.

Table 1. GENERAL SPECIFICATIONS

NOTE: All Parameters are specified at $T = 40^{\circ}$ C unless otherwise noted.

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Figure 1. KAI−0340 Interline CCD Image Sensor

Features

- High Sensitivity
- High Dynamic Range
- Low Noise Architecture
- High Frame Rate
- Electronic Shutter

Applications

- Intelligent Transportation Systems
- Machine Vision
- Scientific

ORDERING INFORMATION

See detailed ordering and shipping information on page 2 of this data sheet.

ORDERING INFORMATION

Table 2. ORDERING INFORMATION − KAI−0340 IMAGE SENSOR

*Not recommended for new designs.

Table 3. ORDERING INFORMATION − EVALUATION SUPPORT

See the ON Semiconductor *Device Nomenclature* document (TND310/D) for a full description of the naming convention used for image sensors. For reference documentation, including information on evaluation kits, please visit our web site at [www.onsemi.com.](http://onsemi.com)

DEVICE DESCRIPTION

Architecture

Figure 2. Sensor Architecture

There are 4 light-shielded rows followed by 488 photoactive rows. The first 4 and the last 4 photoactive rows are buffer rows giving a total of 480 lines of image data.

In the single output mode all pixels are clocked out of the Video L output in the lower left corner of the sensor. The first 12 empty pixels of each line do not receive charge from the vertical shift register. The next 24 pixels receive charge from the left light-shielded edge followed by 648 photosensitive pixels and finally 24 more light-shielded pixels from the right edge of the sensor. The first and last 4 photosensitive pixels are buffer pixels giving a total of 640 pixels of image data.

In the dual output mode the clocking of the right half of the horizontal CCD is reversed. The left half of the image is clocked out Video L and the right half of the image is clocked out Video R. Each row consists of 12 empty pixels followed by 24 light-shielded pixels followed by 324 photosensitive pixels. When reconstructing the image, data from Video R will have to be reversed in a line buffer and appended to the Video L data.

There are no dark reference rows at the top and 4 dark rows at the bottom of the image sensor. The 4 dark rows are not entirely dark and so should not be used for a dark reference level. Use the 24 dark columns on the left or right side of the image sensor as a dark reference.

Of the 24 dark columns, the first and last dark columns should not be used for determining the zero signal level. Some light does leak into the first and last dark columns. Only use the center 22 columns of the 24 column dark reference.

Figure 3. ESD Protection

The ESD protection on the KAI−0340 is implemented using bipolar transistors. The substrate (SUB) forms the common collector of all the ESD protection transistors. The ESD pin is the common base of all the ESD protection transistors. Each protected pin is connected to a separate emitter as shown in Figure 3.

The ESD circuit turns on if the base-emitter junction voltage exceeds 17 V. Care must be taken while operating the image sensor, especially during the power on sequence, to not forward bias the base-emitter or base-collector junctions. If it is possible for the camera power up sequence to forward bias these junctions then diodes D1 and D2 should be added to protect the image sensor. Put one diode D1 between the ESD and VSUB pins. Put one diode D2 on each pin that may forward bias the base-emitter junction. The diodes will prevent large currents from flowing through the image sensor. Note that external diodes D1 and D2 are optional and are only needed if it is possible to forward bias any of the junctions.

Note that diodes D1 and D2 are added external to the KAI−0340.

Pin Description and Device Orientation

Figure 4. Pin Description (Top View)

Table 4. PIN DESCRIPTION

1. The pins are on a 0.050″ spacing

2. If the vertical windowing option is not to be used, then the V1 and V1C pins should be driven from one clock driver. The V2 and V2C pins should also be driven from one clock driver.

3. If the fast dump windowing option is not to be used, then the FD and FDC pins should be driven from the same clock driver.

4. The VOUTR pin is not enabled in the KAI−0340−Single version.

IMAGING PERFORMANCE

Table 5. IMAGING PERFORMANCE OPERATIONAL CONDITIONS

(Unless otherwise noted, Imaging Performance Specifications are measured using the following conditions.)

5. Electronic shutter is not used. Integration time equals frame time.

6. LEDs used: Blue: Nichia NLPB500, Green: Nichia NSPG500S and Red: HP HLMP−8115.

7. For monochrome sensor, only green LED used.

Table 6. IMAGING PERFORMANCE SPECIFICATIONS

Table [6](#page-5-0). IMAGING PERFORMANCE SPECIFICATIONS (continued)

8. Measured at sensor output with constant current load of I_{OUT} = –5 mA and during the floating diffusion reset interval (R high).
9. Last stage only. C_{LOAD} = 10 pF. Then f_{−3dB} = (1 / (2n ⋅ R_{OUT} ⋅ C_{LOAD})).
10.

11. Calculated using quantum efficiency, output amplifier sensitivity, 3200K Plankian source and a CM500S IR-cut filter.

12.This color filter set configuration (Gen1) is not recommended for new designs.

TYPICAL PERFORMANCE CURVES

Quantum Efficiency

Monochrome with Microlens

Monochrome without Microlens

Figure 6. Monochrome without Microlens Quantum Efficiency

Color (Bayer RGB) with Microlens

Angular Quantum Efficiency

Monochrome with Microlens

For the curves marked "Horizontal", the incident light angle is varied in a plane parallel to the HCCD. For the curves marked "Vertical", the incident light angle is varied in a plane parallel to the VCCD.

Figure 8. Angular Quantum Efficiency

Power Estimated

Figure 9. Power

Frame Rates

Frames rates are for continuous mode operation.

Table 7. FRAME RATES

228(H) x 164(V) Center Rows and Columns Dual Outputs

Figure 10. Frame Rates

DEFECT DEFINITIONS

Table 8. DEFECT DEFINITIONS

Defect Map

No defect maps are available for the KAI−0340 image sensor.

TEST DEFINITIONS

Test Regions of Interest

Only the active pixels are used for performance and defect tests.

Test Sub-Regions of Interest

Pixel (640,480)

Over-Clocking

The test system timing is configured such that the sensor is overclocked in both the vertical and horizontal directions. See Figure 12 for a pictorial representation of the regions.

Figure 12. Overclock Regions of Interest

Tests

Global Non-Uniformity

This test is performed with the imager illuminated to a level such that the output is at 70% of saturation (approximately 420 mV). Prior to this test being performed the substrate voltage has been set such that the charge capacity of the sensor is 600 mV. Global non-uniformity is defined as

Global Non−Uniformity - ¹⁰⁰ Active Area Standard Deviation Active Area Signal

Units : % rms

Active Area Signal = Active Area Average − H. Overclock Average

Global Peak-to-Peak Non-Uniformity

This test is performed with the imager illuminated to a level such that the output is at 70% of saturation (approximately 420 mV). Prior to this test being performed the substrate voltage has been set such that the charge capacity of the sensor is 600 mV. The sensor is partitioned into 25 sub-regions of interest, each of which is 128 by 96 pixels in size. The average signal level of each of the 25 sub-regions of interest (ROI) is calculated. The signal level of each of the sub regions of interest is calculated using the following formula:

A[i] = (ROI Average - Horizontal Overclock Average)

Where $i = 1$ to 25. During this calculation on the 25 sub-regions of interest, the maximum and minimum average signal levels are found. The global peak-to-peak non-uniformity is then calculated as:

Global Non-Uniformity =
$$
100 \cdot \left(\frac{A[i] Max. Signal - A[i] Min. Signal}{Active Area Signal} \right)
$$

Units : % pp

Active Area Signal = Active Area Average − H. Overclock Average

Center Non-Uniformity

This test is performed with the imager illuminated to a level such that the output is at 70% of saturation (approximately 420 mV). Prior to this test being performed the substrate voltage has been set such that the charge capacity of the sensor is 600 mV. Defects are excluded for the calculation of this test. This test is performed on the center 100 by 100 pixels (See [Test Regions of Interest](#page-12-0)) of the sensor. Center non-uniformity is defined as:

Center ROI Signal = Center ROI Average − H. Overclock Average

Dark Field Defect Test

This test is performed under dark field conditions. The sensor is partitioned into 25 sub-regions of interest, each of which is 128 by 96 pixels in size. In each region of interest, the median value of all pixels is found. For each region of interest, a pixel is marked defective if it is greater than or equal to the median value of that region of interest plus the defect threshold specified in ["Defect Definitions"](#page-11-0) section.

Bright Field Defect Test

This test is performed with the imager illuminated to a level such that the output is at 70% of saturation (approximately 420 mV). Prior to this test being performed the substrate voltage has been set such that the charge capacity of the sensor is 600 mV. The average signal level of all active pixels is found. The bright and dark thresholds are set as:

Dark Defect Threshold = Active Area Signal \cdot Threshold

Bright Defect Threshold = Active Area Signal \cdot Threshold

The sensor is then partitioned into 25 sub-regions of interest, each of which is 128 by 96 pixels in size. In each region of interest, the average value of all pixels is found. For each region of interest, a pixel is marked defective if it is greater than or equal to the median value of that region of interest plus the bright threshold specified or if it is less than or equal to the median value of that region of interest minus the dark threshold specified.

Example for major bright field defective pixels:

- Average value of all active pixels is found to be 420 mV.
- Dark defect threshold: $420 \text{ mV} \cdot 11\% = 46 \text{ mV}$
- Bright defect threshold: $420 \text{ mV} \cdot 11\% = 46 \text{ mV}$
- Region of interest #1 selected. This region of interest is pixels 1,1 to pixels 128,96.
	- ♦ Median of this region of interest is found to be 420 mV.
	- \triangle Any pixel in this region of interest that is \geq (420 + 46 mV) 466 mV in intensity will be marked defective.
	- ♦ Any pixel in this region of interest that is ≤ (420 − 46 mV) 374 mV in intensity will be marked defective.
- All remaining 24 sub-regions of interest are analyzed for defective pixels in the same manner.

For the color sensor, the threshold for each color channel is determined independently.

OPERATION

Absolute maximum rating is defined as a level or condition that should not be exceeded at any time per the description. If the level or the condition is exceeded, the device will be degraded and may be damaged.

Table 9. ABSOLUTE MAXIMUM RATINGS

Stresses exceeding those listed in the Maximum Ratings table may damage the device. If any of these limits are exceeded, device functionality should not be assumed, damage may occur and reliability may be affected.

13.Noise performance will degrade at higher temperatures.

14.T = 25°C. Excessive humidity will degrade MTTF.

15.Each output. See Figure [13.](#page-15-0) Note that the current bias affects the amplifier bandwidth.

16. With total output load capacitance of $C_L = 10$ pF between the outputs and AC ground.

Table 10. ABSOLUTE VOLTAGE RATINGS BETWEEN PINS

17.Pins with ESD protection are: RL, RR, H1S, H2S, H1BL, H2BL, H1BR, and H2BR.

Table 11. DC OPERATING CONDITIONS

18. The maximum DC current is for one output unloaded and is shown as I_{RD} + I_{SS} in Figure [13](#page-15-0). This is the maximum current that the first two stages of one output amplifier plus the reset drain bias circuit will draw. This value is with V_{OUT} disconnected.

19. The operating value of the substrate voltage, V_{AB} , will be marked on the shipping container for each device. The shipping container will be marked with two V_{AB} voltages. One V_{AB} will be for a 600 mV charge capacity and the other V_{AB} will be for a 1,200 mV charge capacity. The 600 mV charge capacity is for operation of the horizontal clock at frequencies greater than 20 MHz. The 1,200 mV charge capacity V_{AB} value may be used for horizontal clock frequencies at or below 20 MHz.

20.VESD must be more negative than H1L, H2L and RL during sensors operation AND during camera power turn on.

21.**Both VDDL and VDDR must both be supplied.**

22.One output.

23.Refer to Application Note Using Interline CCD Image Sensors in High Intensity Visible Lighting Conditions.

Figure 13. Output Amplifier

AC Operating Conditions

Table 12. CLOCK LEVELS

24.The amplitude of the horizontal clock must be at least 4.5 V.

25.The amplitude of the reset clock must be at least 4.5 V.

26.Refer to Application Note Using Interline CCD Image Sensors in High Intensity Visible Lighting Conditions.

The Figure [14](#page-16-0) shows the DC bias (SUB) and AC clock (VES) applied to the SUB pin. Both the DC bias and AC clock are referenced to ground.

Figure 14. DC Bias and AC Clock Applied to the SUB Pin

TIMING

Timing Requirements

Table 14. TIMING REQUIREMENTS

27.For operation at the minimum HCCD clock period (40 MHz), the substrate voltage must be set to limit the signal at the output to 600 mV. 28.Each clock pulse width is defined for t_{WH} or t_{WL} .

Timing Sequences

Timing Sequence A: Photodiode to VCCD Transfer, Entire Image

Figure 15. Timing Sequence A

Timing Sequence B: Vertical CCD Line Shift and Horizontal CCD Readout of One Line

Figure 16. Timing Sequence B

Timing Sequence C: Photodiode to VCCD Transfer, Center 164 Rows

Figure 17. Timing Sequence C

Timing Sequence D: No Vertical CCD Line Transfer, Readout of One Horizontal CCD Line

Figure 18. Timing Sequence D

Timing Modes

Sensor Architecture

Figure 19. Sensor Architecture

When the sensor is operated in single output mode using the left output, the horizontal CCD is 708 pixels long. This assumes no horizontal over clocking is done.

708

When the sensor is operated in dual output mode, the horizontal CCD is dived into left and right registers. Each half of the register is 360 pixels long. This assumes no horizontal over clocking is done.

One Output Full Field

Figure 20. One Output Full Field

Two Outputs Full Field

Figure 21. Two Outputs Full Field

One Output Center Columns

Figure 22. One Output Center Columns

Two Outputs Center Columns

Figure 23. Two Outputs Center Columns

One Output Center Rows

Figure 24. One Output Center Rows

Two Outputs Center Rows

One Output Center Rows and Columns

Two Outputs Center Rows and Columns

Timing Details

Pixel Timing

Figure 28. Pixel Timing Detail

Vertical Clock Phase 1 − Line Timing Detail

The following timing detail applies if any of the center row timing modes are selected. If the center row timing modes are not to be used, then the V1 and V1C pins should be tied together and driven from one clock driver.

During the line timing, the V1 and V1C rise and fall times need to be identical. Since the V1 capacitance is

approximately twice the V1C capacitance, the clock driver circuits must be adjusted to ensure equal rise and fall times.

The figure below is an example of unacceptable V1 and V1C clock waveforms.

The figures below are examples of acceptable V1 and V1C clock waveforms.

Vertical Clock Phase 2 − Line Timing Detail

The following timing detail applies if any of the center row timing modes are selected. If the center row timing modes are not to be used, then the V2 and V2C pins should be tied together and driven from one clock driver.

During the line timing, the V2 and V2C rise and fall times need to be identical. Since the V2 capacitance is

The figures below are examples of acceptable V2 and V2C clock waveforms.

The following line timing detail applies to all modes. The V1 and V1C clocks must be symmetrical to the V2 and V2C clocks. The figure below is an example of unacceptable V1, V1C, V2 and V2C clock waveforms.

The figures below are of acceptable V1, V1C, V2 and V2C clock waveforms.

approximately twice the V2C capacitance, the clock driver circuits must be adjusted to ensure equal rise and fall times.

The figure below is an example of unacceptable V2 and V2C clock waveforms.

Vertical Clock Phase 1 − Frame Timing Detail

The following timing detail applies if any of the center row timing modes are selected. If the center row timing modes are not to be used, then the V1 and V1C pins should be tied together and driven from one clock driver.

During the frame timing, the V1 and V1C rise and fall times need to be identical. Since the V1 capacitance is approximately twice the V1C capacitance, the clock driver circuits must be adjusted to ensure equal rise and fall times.

The figure below is an example of unacceptable V1 and V1C clock waveforms.

The figures below are examples of acceptable V1 and V1C clock waveforms

Vertical Clock Phase 2 − Frame Timing Detail

The following timing detail applies if any of the center row timing modes are selected. If the center row timing modes are not to be used, then the V2 and V2C pins should be tied together and driven from one clock driver.

During the frame timing, the V2 and V2C rise and fall times need to be identical. Since the V2 capacitance is approximately twice the V2C capacitance, the clock driver circuits must be adjusted to ensure equal rise and fall times.

The figure below is an example of unacceptable V2 and V2C clock waveforms during the frame timing.

The figures below are examples of acceptable V2 and V2C clock waveforms during the frame timing.

Vertical Clock Phases 1 and 2 − Frame Timing Detail

The following frame timing detail applies to all modes. The V1 and V1C clocks must be symmetrical to the V2 and V2C clocks. Also, during the t_{V3rd} timing, the V1 and V2 waveform edges should be aligned to occur at the same time.

The figure below is an example of unacceptable V1, V1C, V2 and V2C clock waveforms.

The figures below are of acceptable V1, V1C, V2 and V2C clock waveforms.

Electronic Shutter Timing

Figure 29. Electronic Shutter Timing

Electronic Shutter − Integration Time Definition

Fast Line Dump Timing

The figure below shows an example of dumping three lines for all rows.

Figure 31. Fast Line Dump Timing

Example HCCD Clock Driver

The HCCD clock inputs should be driven by buffers capable of driving a capacitance of 40 pF and having a full voltage swing of at least 4.7 V. A 74AC04 or equivalent is recommended to drive the HCCD. The HCCD requires a 0.0 to 5.0 V clock. This clock level can be obtained by capacitive coupling and a diode to clamp the high level to

ground. Resistors R2 and R6 are used to dampen the signal to prevent overshoots. The values of resistors R2 and R6 shown in the schematics below are only suggestions. The actual value required should be selected for each camera design.

Single Output Only:

Figure 32. Single Output Only

Dual Output Only:

Figure 33. Dual Output Only

Selectable Single or Dual Output:

Figure 34. Selectable Single or Dual Output

The inputs to the above circuits, H1 and H2, are 5 V logic from the timing generator (a programmable gate array for example). If the camera is to have selectable single or dual output modes of operation, then the timing logic needs to

generate two extra signals for the H1BR and H2BR timing. For single output mode program the timing such that $H1BR = H2$ and $H2BR = H1$. For dual output mode program the timing such that $H1BR = H1$ and $H2BR = H2$.

STORAGE AND HANDLING

Table 15. CLIMATIC REQUIREMENTS

Description	Symbol	Minimum	Maximum	Unit
Temperature (Note 29)	ST	-55	80	
Humidity (Note 30)	RН		90	70

29.Long-term exposure toward the maximum temperature will accelerate color filter degradation.

 $30.\text{T} = 25^{\circ}\text{C}$. Excessive humidity will degrade MTTF.

For information on ESD and cover glass care and cleanliness, please download the *Image Sensor Handling and Best Practices* Application Note (AN52561/D) from [www.onsemi.com.](http://onsemi.com)

For information on environmental exposure, please download the *Using Interline CCD Image Sensors in High Intensity Lighting Conditions* Application Note (AND9183/D) from [www.onsemi.com](http://onsemi.com).

For information on soldering recommendations, please download the Soldering and Mounting Techniques Reference Manual (SOLDERRM/D) from [www.onsemi.com.](http://onsemi.com)

For quality and reliability information, please download the *Quality & Reliability* Handbook (HBD851/D) from [www.onsemi.com.](http://onsemi.com)

For information on device numbering and ordering codes, please download the *Device Nomenclature* technical note (TND310/D) from [www.onsemi.com](http://onsemi.com).

For information on Standard terms and Conditions of Sale, please download [Terms and Conditions](http://www.onsemi.com/site/pdf/ONSEMI_T&C.pdf) from [www.onsemi.com.](http://onsemi.com)

MECHANICAL INFORMATION

Completed Assembly

Notes:

31.See Available Part Configurations in Ordering Section for a description of the marking code.

32.Lid shall not extend beyond ceramic edge.

33.Light shield shown for reference only. Quartz version is smaller.

34.Units: IN [mm].

Figure 35. Completed Assembly

Notes:

35.Center of image area is offset from center of package by (0.00, 0.00) IN nominal.

36.Die is aligned within ±1 degree of any package cavity edge.

37.Units: IN [mm].

Figure 36. Die to Package Alignment

Glass

Clear Cover Glass

Notes:

38.Substrate: Schott D−263T eco or equivalent.

39.Top and Bottom edge chamfers = 0.008 [0.20].

40.Corner chamfers = 0.020 [0.50].

41.Dust, scratch, dig specification: 10 microns max.

42.Units: IN [mm].

Quartz Cover Glass

Notes:

- 43.Substrate: SK1300.
- 44.Top and Bottom edge chamfers = 0.008 [0.20].
- 45.Corner chamfers = 0.020 [0.50].
- 46.Dust, scratch, dig specification: 10 microns max.
- 47.Units: IN [mm].

Figure 38. Quartz Cover Glass Drawing

Glass Transmission

Clear Cover Glass

Quartz Cover Glass

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